

PA-IDC

QUERY CONTROL FORM		RTIS USE ONLY	
Application No. <u>10/783,772</u>	Prepared by <u>NPB</u>	Tracking Number <u>06017856</u>	
Examiner-GAU <u>MULPURI-</u>	Date <u>10/19/04</u>	Week Date <u>10/04/04</u>	
<u>2812</u>	No. of queries <u>1</u>	<u>IPW (E)</u>	

JACKET			
a. Serial No.	f. Foreign Priority	k. Print Claim(s)	p. PTO-1449
b. Applicant(s)	g. Disclaimer	l. Print Fig.	q. PTOL-85b
c. Continuing Data	h. Microfiche Appendix	m. Searched Column	r. Abstract
d. PCT	i. Title	n. PTO-270/328	s. Sheets/Figs
e. Domestic Priority	j. Claims Allowed	o. PTO-892	t. Other

SPECIFICATION	MESSAGE
a. Page Missing	<p><i>Per Amendment dated 09/22/04 (NOA), original claims 9 and 15 are cancelled, but these claims are still shown as allowed in NOA and index of claims.</i></p> <p><i>Please advise/correct.</i></p> <p><i>Shankar</i></p>
b. Text Continuity	
c. Holes through Data	
d. Other Missing Text	
e. Illegible Text	
f. Duplicate Text	
g. Brief Description	
h. Sequence Listing	
i. Appendix	
j. Amendments	
k. Other	initials <i>MM</i>
CLAIMS	RESPONSE
a. Claim(s) Missing	
b. Improper Dependency	
c. Duplicate Numbers	
d. Incorrect Numbering	
<u>e. Index Disagrees</u>	
f. Punctuation	
g. Amendments	
h. Bracketing	
i. Missing Text	
j. Duplicate Text	
k. Other	initials

Art Unit: 2812

In line 14 after "photoresist film" add --- to form plural electrode regions with surface substantially coplanar with the dielectric layer ---

In line 19 and line 20 replace electrode region" with ---one of the electrode regions---

In line 22 before "metal" delete "dimple"

In line 23 replace "portion" with ---contact--

In line 41 replace "a" with --an--

In line 49 replace "having desired shape" with ---having plural electrode regions with surface substantially coplanar with the dielectric layer----

In claim 8

In line 1 replace "37" with ---1---

In line 2 replace "actuating" with ---- actuating---

Cancel claims 9-12

In claim 13:

In line 4 after "conductive layer" add ---, wherein plurality of conductors having surface substantially coplanar with the dielectric layer---

In line 9 before "metal" delete "dimple"

In line 9 after " form a dimple" add ---contact--

In line 12 before "top" replace "the" with --a--

In line 23 replace "second" with ---first--

In line 26 replace "a" with ---an--

Art Unit: 2812

In 34 replace "having desired shape" with —having plurality conductors with surface substantially coplanar with the dielectric layer----

Cancel claims 15-24

Allowable Subject Matter

The following is an examiner's statement of reasons for allowance: Prior art neither teach nor suggest forming electromechanical device having plural electrode regions with surface substantially coplanar with the dielectric layer (see Fig. 6C) and also does not forming electromechanical device etching through sacrificial layer to form dimple portion of a top electrode space proximate electrode region and depositing dimple metal layer in dimple portion to form dimple contact portion.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Savitri Mulpuri whose telephone number is 571-272-1677. The examiner can normally be reached on Mo-Fri from 8 a.m. to 4.30 p.m.